

Coating 114436

Magnetron sputtered system

$HR(0^\circ, 1360-1560\text{nm}) > 99.9\% + HR(0^\circ, 2320-2870\text{nm}) > 99.7\%$

$+ R(0^\circ, 930-1080\text{nm}) < 2\%$

Goal: $HR(0^\circ, 2320-2870\text{nm}) > 99.8\%$

fig. 1 reflection, 0°

